

Paths of analysis*

C25

Synthia

March 3, 2022

1 Analysis parameters

Analysis type: Automatic Retrosynthesis

Rules: none selected

Filters: FGI, FGI with protections

Max. paths returned: 5

Max. iterations: 300

Commercial:

1. Max. molecular weight - 1000 g/mol
2. Max. price - 1000 \$/g

Published:

1. Max. molecular weight - 1000 g/mol
2. Popularity - 10

My Stockroom:

1. Max. molecular weight - 1000 g/mol

Reaction scoring formula: $\text{TUNNEL_COEF} * \text{FGI_COEF} * \text{STEP} * 20 + 100000 * (\text{CONFLICT} + \text{NON_SELECTIVITY} + \text{FILTERS} + \text{PROTECT})$

Chemical scoring formula: $\text{SMALLER}^3, \text{SMALLER}^{1.5}$

Min. search width: 400

Max. reactions per product: 60

Strategies: none selected

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FGI Coeff: 0

JSON Parameters: {}

2 Paths

3 paths found. *Paths are sorted by score. Reactions are sorted in appearance order for each path.*

2.1 Path 1

Score: 277.20

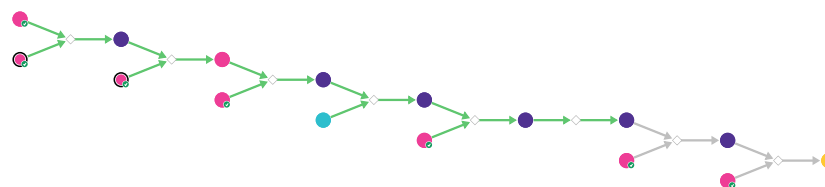
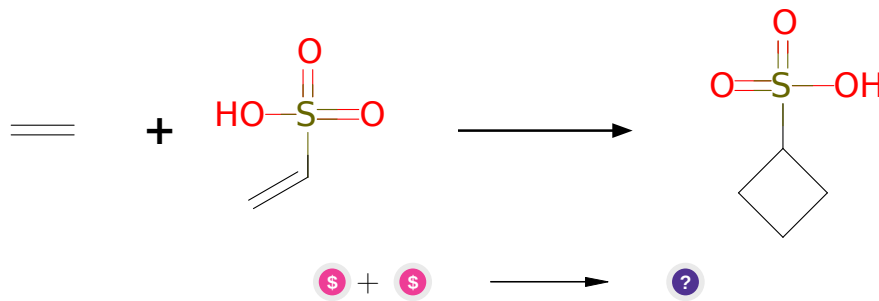


Figure 1: Outline of path 1

2.1.1 [2+2] photocycloaddition



Substrates:

1. Sodium vinylsulfonate solution - *available at Sigma-Aldrich*
2. Ethene - *available at Sigma-Aldrich*

Products:

1. O=S(=O)(O)C1CCC1

Typical conditions: light

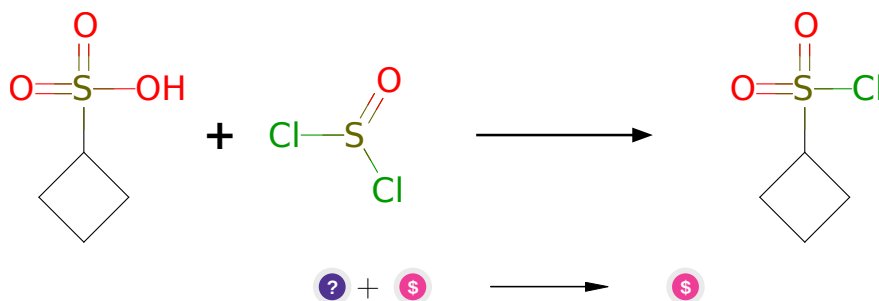
Protections: none

Yield: moderate

Reference: [10.1002/0471264180.or044.02](#) and [10.1021/acs.chemrev.5b00723](#) and [10.1007/s11426-015-5516-5](#) and [10.1016/S0957-4166\(00\)80211-6](#) and CN107805197A, p.0009 and [10.1039/c2sc20658g](#)

Retrosynthesis ID: 1225

2.1.2 Synthesis sulfonyl chlorides from sulfonic acids



Substrates:

1. O=S(=O)(O)C1CCC1
2. Thionyl chloride - [available at Sigma-Aldrich](#)

Products:

1. Cyclobutanesulfonyl chloride - [AstaTech](#)

Typical conditions: SOCl₂.DMF.20C

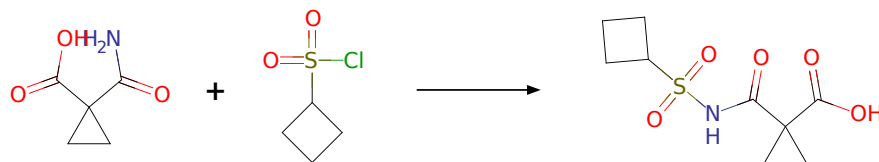
Protections: none

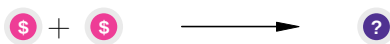
Yield: good

Reference: Patent: WO2003106445 A1, 2003

Retrosynthesis ID: 2000

2.1.3 Sulfonylation of amides





Substrates:

1. Cyclobutanesulfonyl chloride - *AstaTech*
2. 1-(Aminocarbonyl)-1-cyclopropanecarboxylic acid - *available at Sigma-Aldrich*

Products:

1. O=C(O)C1(C(=O)NS(=O)(=O)C2CCC2)CC1

Typical conditions: Py.RSO₂Cl

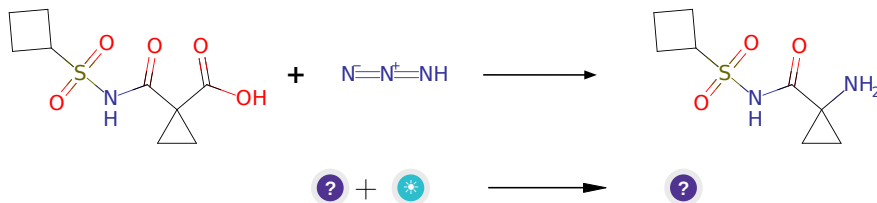
Protections: none

Yield: good

Reference: [10.1021/ja9945313](#) AND [10.1016/j.ejmech.2013.04.028](#)
 AND [10.1039/c5ra14001c](#) AND [10.1016/j.bmcl.2013.12.043](#) AND [10.1016/j.tetasy.2012.08.013](#)

Retrosynthesis ID: 14787

2.1.4 Schmidt Reaction



Substrates:

1. O=C(O)C1(C(=O)NS(=O)(=O)C2CCC2)CC1
2. hydrazoic acid

Products:

1. NC1(C(=O)NS(=O)(=O)C2CCC2)CC1

Typical conditions: azide.H+.40C

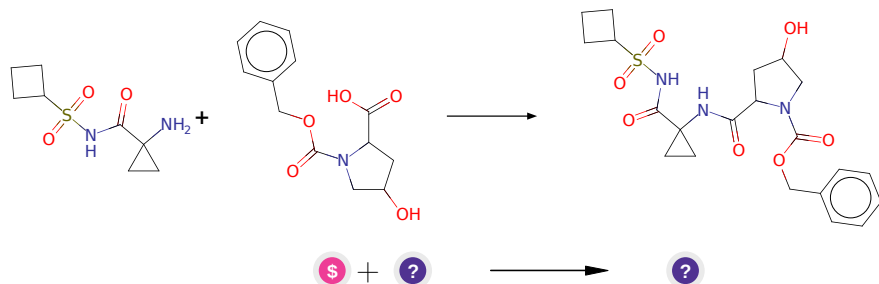
Protections: none

Yield: moderate

Reference: [10.1039/B505080D](#)

Retrosynthesis ID: 11704

2.1.5 Amide coupling



Substrates:

1. Z-Hyp-OH - *available at Sigma-Aldrich*
2. NC1(C(=O)NS(=O)(=O)C2CCC2)CC1

Products:

1. O=C(NC1(C(=O)NS(=O)(=O)C2CCC2)CC1)C1CC(O)CN1C(=O)OCc1ccccc1

Typical conditions: DCC.DCM or EDC.DCM or SOCl₂.DCM

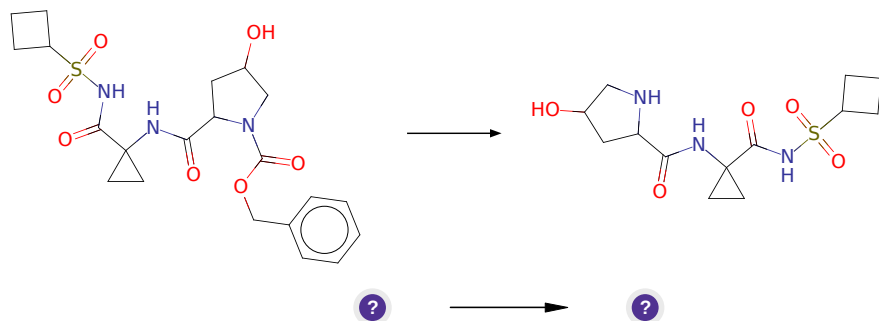
Protections: none

Yield: good

Reference: *10.1021/cr100048w* and *10.1039/B701677H* and *10.1039/C5RA24527C* and *10.3727/000000006783981206* and *10.1021/np060007f* and *10.1021/jo00012a058* and *10.1016/j.bmcl.2007.08.037* and *10.1039/C0OB00355G* and *10.1021/jm500031w* (p.3056) and *10.1016/j.tet.2011.03.046*

Retrosynthesis ID: 10087

2.1.6 Cleavage of benzyloxycarbamates



Substrates:

1. O=C(NC1(C(=O)NS(=O)(=O)C2CCC2)CC1)C1CC(O)CN1C(=O)OCc1ccccc1

Products:

1. O=C(NC1(C(=O)NS(=O)(=O)C2CCC2)CC1)C1CC(O)CN1

Typical conditions: H₂.Pd/C

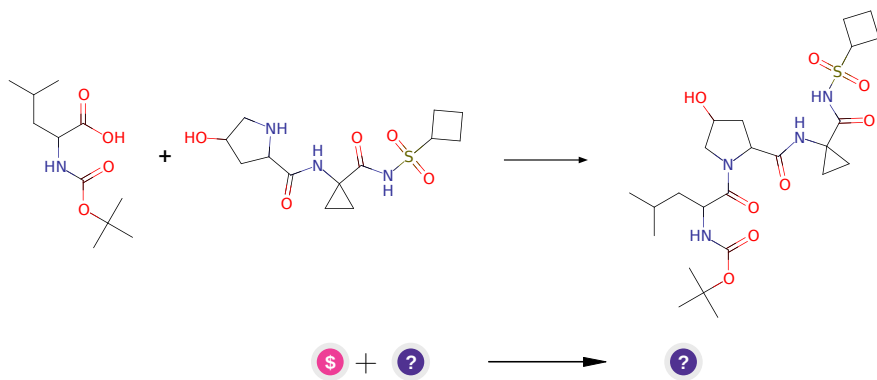
Protections: none

Yield: good

Reference: [10.1021/jm070755h](#) and [10.1021/jm2016057](#) and [10.1055/s-0033-1340215](#) and [10.1016/S0040-4039\(03\)01181-X](#)

Retrosynthesis ID: 9990024

2.1.7 Amide coupling



Substrates:

1. 2-[(tert-butoxy)carbonyl]amino-4-methylpentanoic acid - *available at Sigma-Aldrich*

2. O=C(NC1(C(=O)NS(=O)(=O)C2CCC2)CC1)C1CC(O)CN1

Products:

1. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)N1CC(O)CC1C(=O)NC1(C(=O)NS(=O)(=O)C2CCC2)CC1

Typical conditions: DCC.DCM or EDC.DCM or SOCl₂.DCM

Protections: none

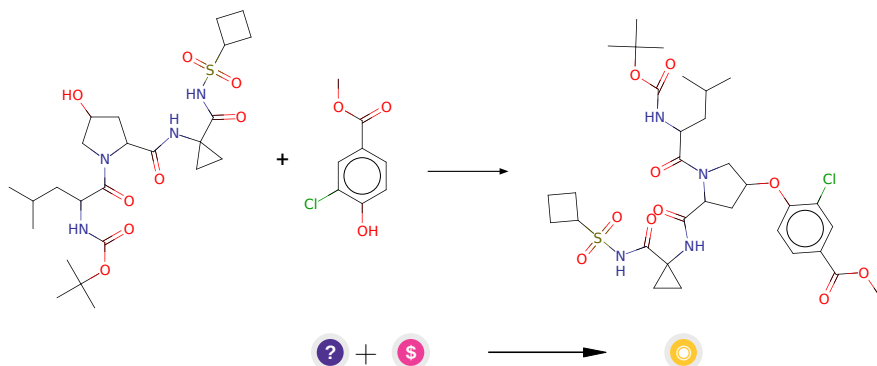
Yield: good

Reference: [10.1021/ol400686f](#) and [10.1021/jo00200a057](#) and [10.1021/cr100048w](#) and [10.1039/B701677H](#) and [10.1039/C5RA24527C](#) and

10.3727/00000006783981206 and 10.1021/np060007f and 10.1021/jo00012a058
 and 10.1016/j.bmcl.2007.08.037 and 10.1039/C0OB00355G and
 10.1021/jm500031w (p.3056) and 10.1016/j.tet.2011.03.046

Retrosynthesis ID: 9147

2.1.8 Mitsunobu reaction



Substrates:

1. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)N1CC(O)CC1C(=O)NC1(C(=O)NS(=O)(=O)C2CCC2)CC1
2. Methyl 3-chloro-4-hydroxybenzoate - *available at Sigma-Aldrich*

Products:

1. COC(=O)c1ccc(OC2CC(C(=O)NC3(C(=O)NS(=O)(=O)C4CCC4)CC3)N(C(=O)C(CC(C)C)NC(=O)C

Typical conditions: DEAD.or.DCAD.or.DIAD.PPh3

Protections: none

Yield: good

Reference: DOI: 10.1021/jo0345751 AND 10.1021/ol0618757

Retrosynthesis ID: 7562

2.2 Path 2

Score: 393.79

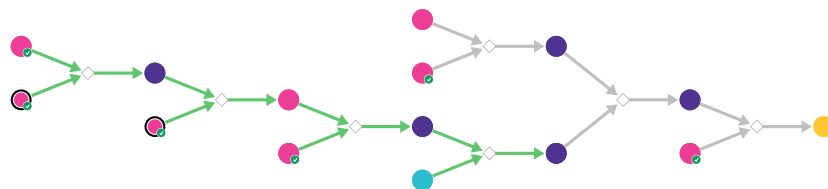
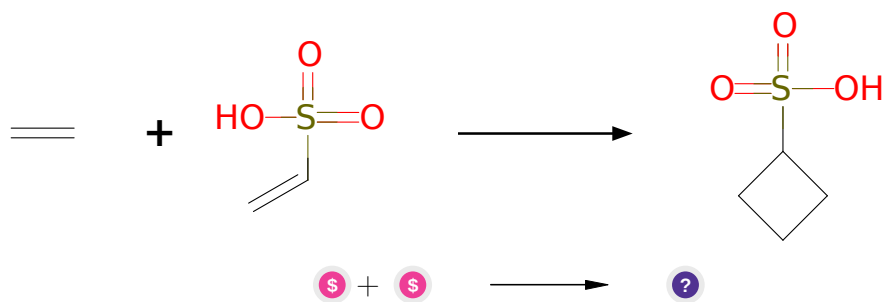


Figure 2: Outline of path 2

2.2.1 [2+2] photocycloaddition



Substrates:

1. Sodium vinylsulfonate solution - *available at Sigma-Aldrich*
2. Ethene - *available at Sigma-Aldrich*

Products:

1. O=S(=O)(O)C1CCC1

Typical conditions: light

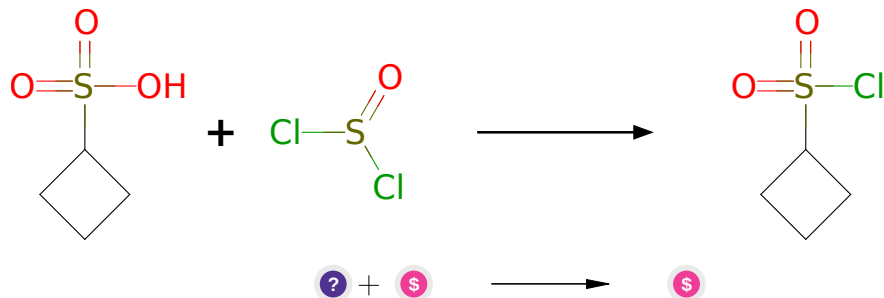
Protections: none

Yield: moderate

Reference: [10.1002/0471264180.or044.02](#) and [10.1021/acs.chemrev.5b00723](#)
and [10.1007/s11426-015-5516-5](#) and [10.1016/S0957-4166\(00\)80211-6](#) and
CN107805197A, p.0009 and [10.1039/c2sc20658g](#)

Retrosynthesis ID: 1225

2.2.2 Synthesis sulfonyl chlorides from sulfonic acids



Substrates:

1. O=S(=O)(O)C1CCC1
2. Thionyl chloride - *available at Sigma-Aldrich*

Products:

1. Cyclobutanesulfonyl chloride - *AstaTech*

Typical conditions: SOCl₂.DMF.20C

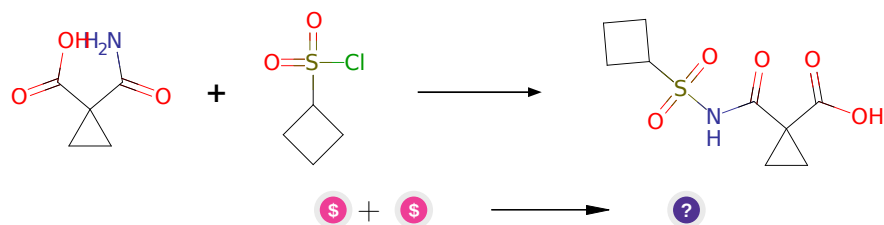
Protections: none

Yield: good

Reference: Patent: WO2003106445 A1, 2003

Retrosynthesis ID: 2000

2.2.3 Sulfonylation of amides



Substrates:

1. Cyclobutanesulfonyl chloride - *AstaTech*
2. 1-(Aminocarbonyl)-1-cyclopropanecarboxylic acid - *available at Sigma-Aldrich*

Products:

1. O=C(O)C1(C(=O)NS(=O)(=O)C2CCC2)CC1

Typical conditions: Py.RSO₂Cl

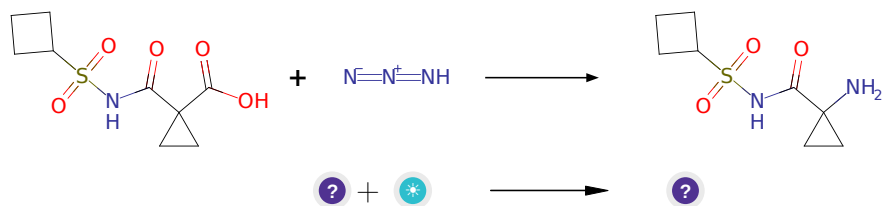
Protections: none

Yield: good

Reference: [10.1021/ja9945313](#) AND [10.1016/j.ejmech.2013.04.028](#)
AND [10.1039/c5ra14001c](#) AND [10.1016/j.bmcl.2013.12.043](#) AND
[10.1016/j.tetasy.2012.08.013](#)

Retrosynthesis ID: 14787

2.2.4 Schmidt Reaction



Substrates:

1. O=C(O)C1(C(=O)NS(=O)(=O)C2CCC2)CC1
2. hydrazoic acid

Products:

1. NC1(C(=O)NS(=O)(=O)C2CCC2)CC1

Typical conditions: azide.H+.40C

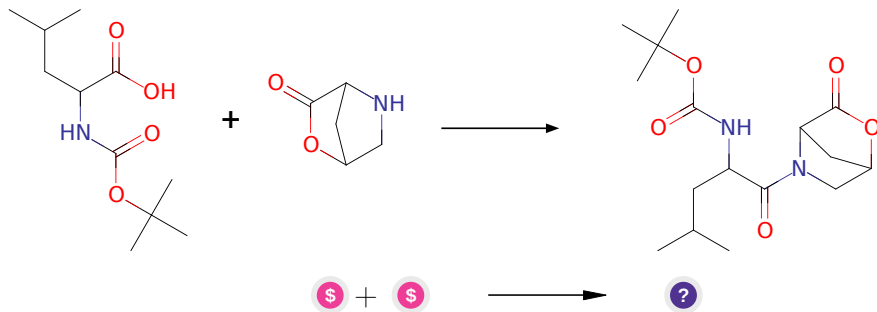
Protections: none

Yield: moderate

Reference: [10.1039/B505080D](#)

Retrosynthesis ID: 11704

2.2.5 Amide coupling



Substrates:

1. cis-4-hydroxy-proline lactone - *Enamine*
2. 2-[(tert-butoxy)carbonyl]amino-4-methylpentanoic acid - *available at Sigma-Aldrich*

Products:

1. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)N1CC2CC1C(=O)O2

Typical conditions: DCC.DCM or EDC.DCM or SOCl₂.DCM

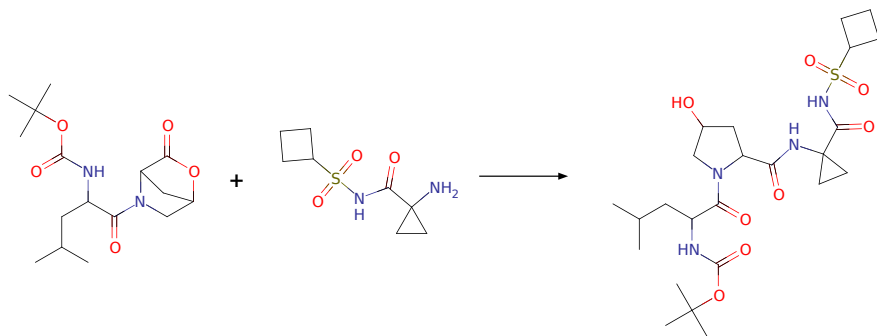
Protections: none

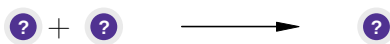
Yield: good

Reference: [10.1021/ol400686f](#) and [10.1021/jo00200a057](#) and [10.1021/cr100048w](#) and [10.1039/B701677H](#) and [10.1039/C5RA24527C](#) and [10.3727/000000006783981206](#) and [10.1021/np060007f](#) and [10.1021/jo00012a058](#) and [10.1016/j.bmcl.2007.08.037](#) and [10.1039/C0OB00355G](#) and [10.1021/jm500031w](#) (p.3056) and [10.1016/j.tet.2011.03.046](#)

Retrosynthesis ID: 9147

2.2.6 Intramolecular amidation of esters





Substrates:

1. NC1(C(=O)NS(=O)(=O)C2CCC2)CC1
2. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)N1CC2CC1C(=O)O2

Products:

1. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)N1CC(O)CC1C(=O)NC1(C(=O)NS(=O)(=O)C2CCC2)CC1

Typical conditions: DABAL-(Me)₃.THF.cooling

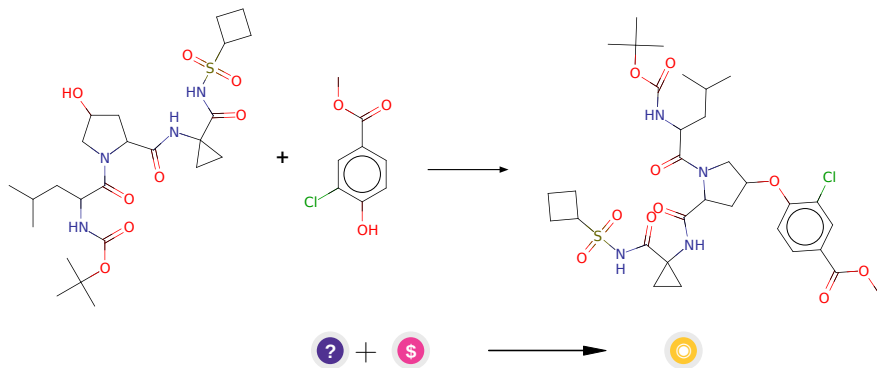
Protections: none

Yield: good

Reference: [10.1016/j.tetlet.2006.06.004](#) and [10.1246/cl.1987.803](#) and
[10.1016/j.polymer.2013.01.040](#) and [10.1016/j.tetasy.2003.11.026](#) and
[10.1021/ol050773y](#)

Retrosynthesis ID: 5035

2.2.7 Mitsunobu reaction



Substrates:

1. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)N1CC(O)CC1C(=O)NC1(C(=O)NS(=O)(=O)C2CCC2)CC1
2. Methyl 3-chloro-4-hydroxybenzoate - *available at Sigma-Aldrich*

Products:

1. COC(=O)c1ccc(OC2CC(C(=O)NC3(C(=O)NS(=O)(=O)C4CCC4)CC3)N(C(=O)C(CC(C)C)NC(=O)C

Typical conditions: DEAD.or.DCAD.or.DIAD.PPh₃

Protections: none

Yield: good

Reference: DOI: [10.1021/jo0345751](https://doi.org/10.1021/jo0345751) AND [10.1021/ol0618757](https://doi.org/10.1021/ol0618757)

Retrosynthesis ID: 7562

2.3 Path 3

Score: 435.11

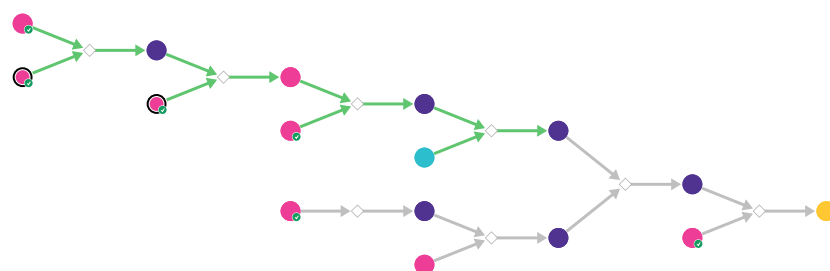
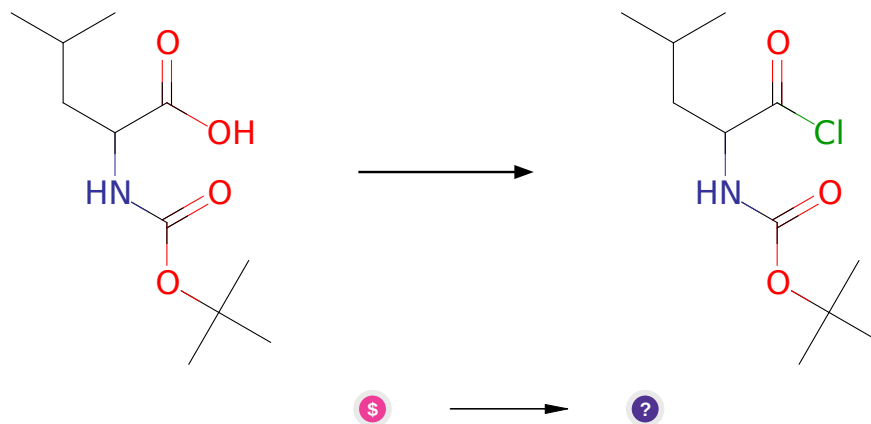


Figure 3: Outline of path 3

2.3.1 Synthesis of acid chlorides from carboxylic acids



Substrates:

- 2-[(tert-butoxy)carbonyl]amino-4-methylpentanoic acid - *available at Sigma-Aldrich*

Products:

1. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)Cl

Typical conditions: oxalyl.chloride.or.SOCl₂

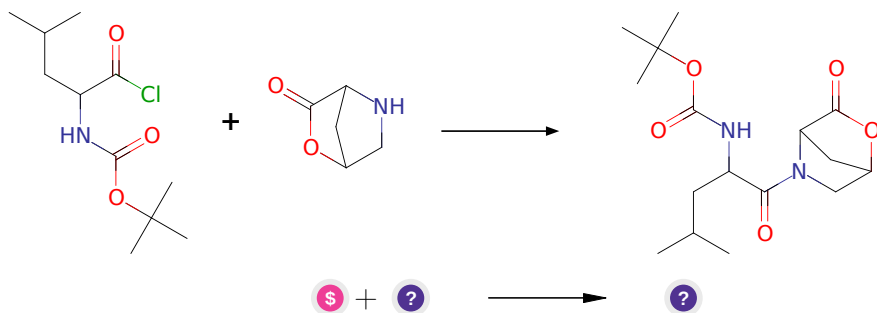
Protections: none

Yield: good

Reference: [10.1002/adsc.200303011](#) and [10.3390/50500714](#)

Retrosynthesis ID: 24405

2.3.2 Synthesis of tertiary amides from acid chlorides



Substrates:

1. cis-4-hydroxy-proline lactone - *Enamine*

2. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)Cl

Products:

1. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)N1CC2CC1C(=O)O2

Typical conditions: TEA.DCM.rt

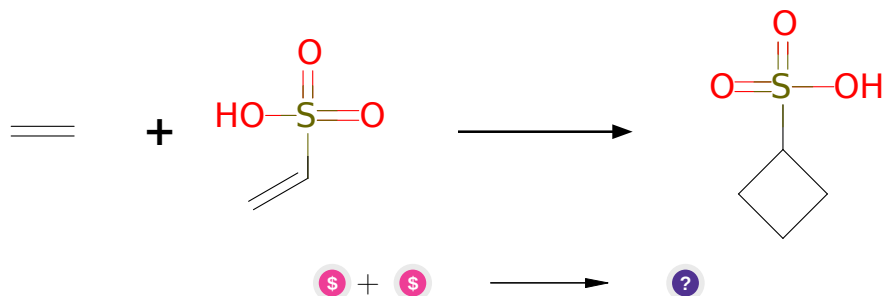
Protections: none

Yield: moderate

Reference: DOI: [10.1016/j.bmcl.2008.08.004](#) and [10.1016/j.tetlet.2008.05.010](#)

Retrosynthesis ID: 9146

2.3.3 [2+2] photocycloaddition



Substrates:

1. Sodium vinylsulfonate solution - *available at Sigma-Aldrich*
2. Ethene - *available at Sigma-Aldrich*

Products:

1. O=S(=O)(O)C1CCC1

Typical conditions: light

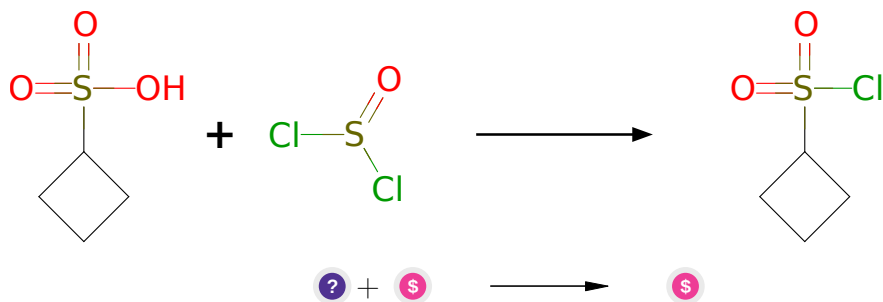
Protections: none

Yield: moderate

Reference: [10.1002/0471264180.or044.02](#) and [10.1021/acs.chemrev.5b00723](#) and [10.1007/s11426-015-5516-5](#) and [10.1016/S0957-4166\(00\)80211-6](#) and CN107805197A, p.0009 and [10.1039/c2sc20658g](#)

Retrosynthesis ID: 1225

2.3.4 Synthesis sulfonyl chlorides from sulfonic acids



Substrates:

1. O=S(=O)(O)C1CCC1

2. Thionyl chloride - *available at Sigma-Aldrich*

Products:

1. Cyclobutanesulfonyl chloride - *AstaTech*

Typical conditions: SOCl₂.DMF.20C

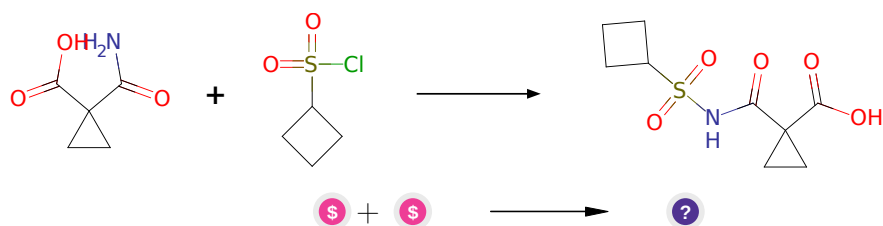
Protections: none

Yield: good

Reference: Patent: WO2003106445 A1, 2003

Retrosynthesis ID: 2000

2.3.5 Sulfonylation of amides



Substrates:

1. Cyclobutanesulfonyl chloride - *AstaTech*
2. 1-(Aminocarbonyl)-1-cyclopropanecarboxylic acid - *available at Sigma-Aldrich*

Products:

1. O=C(O)C1(C(=O)NS(=O)(=O)C2CCC2)CC1

Typical conditions: Py.RSO₂Cl

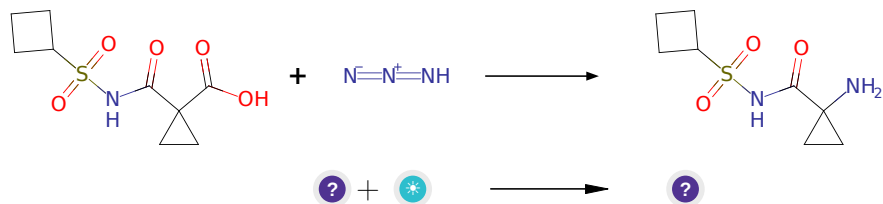
Protections: none

Yield: good

Reference: *10.1021/ja9945313* AND *10.1016/j.ejmech.2013.04.028*
AND *10.1039/c5ra14001c* AND *10.1016/j.bmcl.2013.12.043* AND *10.1016/j.tetasy.2012.08.013*

Retrosynthesis ID: 14787

2.3.6 Schmidt Reaction



Substrates:

- O=C(O)C1(C(=O)NS(=O)(=O)C2CCC2)CC1
- hydrazoic acid

Products:

- NC1(C(=O)NS(=O)(=O)C2CCC2)CC1

Typical conditions: azide.H+.40C

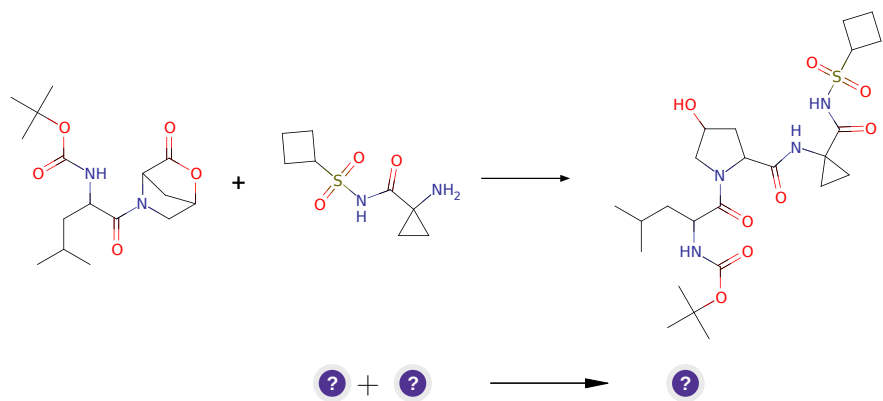
Protections: none

Yield: moderate

Reference: [10.1039/B505080D](#)

Retrosynthesis ID: 11704

2.3.7 Intramolecular amidation of esters



Substrates:

- NC1(C(=O)NS(=O)(=O)C2CCC2)CC1
- CC(C)CC(NC(=O)OC(C)(C)C)C(=O)N1CC2CC1C(=O)O2

Products:

1. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)N1CC(O)CC1C(=O)NC1(C(=O)NS(=O)(=O)C2CCC2)CC1

Typical conditions: DABAL-(Me)₃.THF.cooling

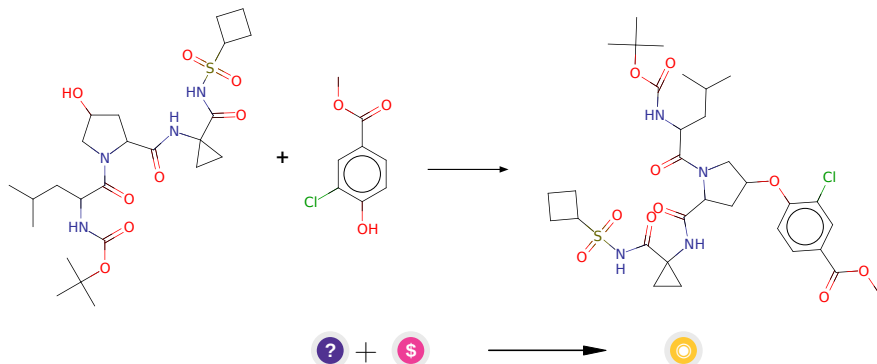
Protections: none

Yield: good

Reference: [10.1016/j.tetlet.2006.06.004](#) and [10.1246/cl.1987.803](#) and
[10.1016/j.polymer.2013.01.040](#) and [10.1016/j.tetasy.2003.11.026](#) and
[10.1021/ol050773y](#)

Retrosynthesis ID: 5035

2.3.8 Mitsunobu reaction



Substrates:

1. CC(C)CC(NC(=O)OC(C)(C)C)C(=O)N1CC(O)CC1C(=O)NC1(C(=O)NS(=O)(=O)C2CCC2)CC1
2. Methyl 3-chloro-4-hydroxybenzoate - [available at Sigma-Aldrich](#)

Products:

1. COC(=O)c1ccc(OC2CC(C(=O)NC3(C(=O)NS(=O)(=O)C4CCC4)CC3)N(C(=O)C(CC(C)C)NC(=O)C

Typical conditions: DEAD.or.DCAD.or.DIAD.PPh₃

Protections: none

Yield: good

Reference: DOI: [10.1021/jo0345751](#) AND [10.1021/ol0618757](#)

Retrosynthesis ID: 7562